IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Chopra et al.

Serial No.: 10/620,002

Filed: July 14, 2003

FOR: SLURRY FOR USE WITH FIXED-ABRASIVE POLISHING PADS IN POLISHING SEMICONDUCTOR DEVICE CONDUCTIVE STRUCTURES THAT INCLUDE COPPER AND A COPPER

BARRIER (as amended)

Confirmation No.: 7481

Examiner: L. Umez-Eronini

Group Art Unit: 1765

Attorney Docket No.: 2269-4373.2US (00-0036.02/US) VIA ELECTRONIC FILING September 14, 2007

AMENDMENT ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION (RCE)

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Examiner:

This Amendment follows the final Office Action of April 20, 2007, and the Advisory Action of August 14, 2007, the shortened statutory period for response to which expired on August 14, 2007. This Amendment, and the RCE that it accompanies, are being filed on September 14, 2007, with a petition for (one month) extension of time and the appropriate fee.

A listing of claims, in which revisions to the claims are presented, begins on page 2 of this paper; and

Remarks start at page 6 of this paper.